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Nano-laminated thin film metallic glass design for outstanding mechanical properties

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ABSTRACT

We report the enhancement of fracture toughness and strength of a cobalt tantalum-based metallic glass thin film with increasing boron content. The improvement of the mechanical performance is attributed to the formation of a compositionally lamellar compared to uniform glass microstructure, which becomes thinner with increasing boron content as revealed by transmission electron microscopy. Compositional variations across the lamellar structure are revealed by atom probe tomography. Cobalt- and boron-rich regions alternate sequentially, whereas tantalum exhibits slight variations across the lamellae. Our results can be utilized in future design efforts for metallic glass thin films with outstanding mechanical performance.

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Metallic glasses exhibit a combination of high strength and toughness which make them an interesting material class for applications such as micro-gears, for instance in high precision endoscopes [1, 2]. However, as these medical tools continuously decrease in size, micro-gears need to decrease in size accordingly, resulting in increased applied stresses during operation. In order to reduce the risk of brittle failure, tougher metallic glasses with high strength are required in that context [3].

For the design of tough metallic glasses, a universal relationship between Poisson's ratio and brittle-ductile transition has been suggested by Lewandowski et al. in 2005 [4]. However, as only the elastic behavior of metallic glasses is considered by the Poisson's ratio, there is an ongoing discussion in literature about the reliability of this criterion regarding ductility [5–8]. Based on theoretical and experimental data of Co–Cu and Pd-based metallic glass systems, we have recently demonstrated that Poisson's ratio alone is not a universal predictor of the brittle-ductile transition. Instead we have proposed a design concept for damage-tolerant metallic glasses, where the low fraction of bonds stemming from hybridized states compared to the overall bonding serves as a fingerprint for damage tolerance [9]. While this assessment is based on a theoretical and experimental appraisal of homogeneous metallic glass systems which are without exception consistent with the notion put forward in Schnabel et al. [9], the here reported nano-

lamellar Co-based metallic glass exhibiting a record fracture strength cannot be predicted based on any design notion available today.

To evaluate the influence of metal-metalloid bonding on the stiffness and damage-tolerance of metallic glasses, we have systematically investigated the influence of Co–B bonds in combinatorial Co-Ta-B metallic glass thin films (MGTFs) by experimental and theoretical methods. In this study, Co-Ta-B MGTFs were magnetron sputtered on Si (100) wafers with a diameter of 50.8 mm for chemical and mechanical characterization as well as on polyimide substrates for synchrotron X-ray diffraction (XRD) for topology analysis [10]. Data from 2D-XRD analysis of a representative film and with a substrate is shown in Supplementary Fig. 1. A lab-scale ultrahigh vacuum chamber was utilized for the production of the MGTFs and it was operated at a base pressure in the range of $5 \cdot 10^{-6}$ Pa. A $\text{Co}_{88}\text{Ta}_{12}$ and a B target were used for the deposition with a purity of 99.9% and 99.5%, respectively. The magnetrons were tilted 45° from the substrate normal and no substrate rotation was employed. For the CoTa compound and B elemental targets, a direct current and radio frequency power supply were used, respectively. The power densities applied were 0.4 W/cm^2 for the CoTa target and 8.4 W/cm^2 for the B target. A film thickness of $2.5 \mu\text{m}$ was obtained.

Micro-cantilever bending experiments were carried out in situ in a scanning electron microscope (JEOL-JSM 2000) equipped with an ASMEC UNAT-2 indenter. 80 cantilevers were micro-machined using a focused ion-beam (FIB) microscope (FEI Helios NanoLab 600i dual-beam FIB) following the procedure described in Ref. [11]. A schematic illustration of the lamellae orientation with respect to nanoindentation and cantilever tests is shown in the Supplementary Fig. 2. Prior to FIB

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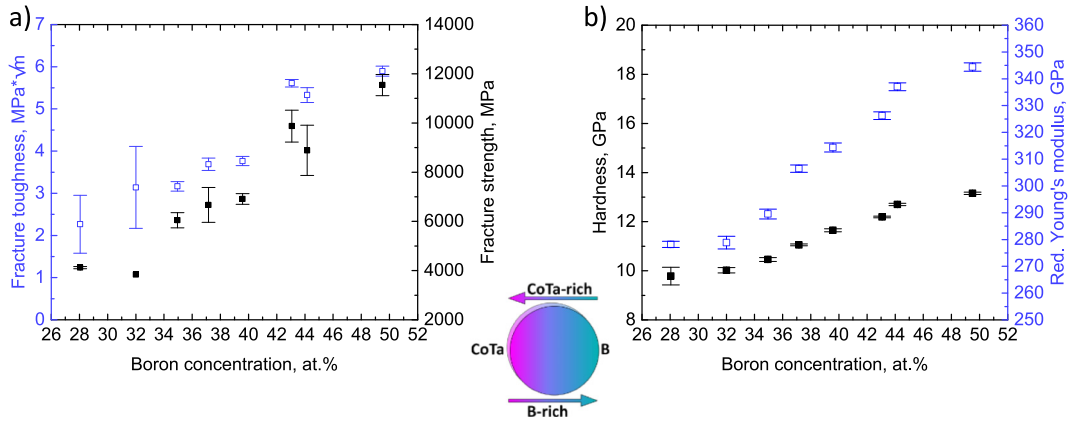


Fig. 1. Micro-mechanical testing of the combinatorial CoTaB metallic glass thin film. a) Fracture toughness and fracture strength graphs as a function of boron content as revealed by micro-cantilever bending tests. b) Young's modulus and hardness as a function of boron content measured by nanoindentation. The error bars correspond to the standard deviation.

milling, a free-standing film was obtained by selectively etching away the Si substrate, using a 30% KOH solution at 80 °C for 45 min [12, 13]. Five un-notched and five pre-notched cantilevers with size $18 \times 2.5 \times 2.5 \mu\text{m}^3$ were fabricated and tested for eight different compositions to measure fracture strength and fracture toughness.

Bending tests were carried out in displacement-controlled mode using a constant displacement rate of 5 nm/s. A conical tip ($1 \mu\text{m}$ tip radius) was employed for the experiments. Fracture toughness, K_{IC} , was evaluated following linear elastic fracture mechanics (LEFM):

$$K_{IC} = \frac{F_{max} L}{B w^2} f\left(\frac{a}{w}\right) \quad (1)$$

where F_{max} is the maximum load before fracture, L is the beam length, B the beam width, w the beam thickness, and a the notch depth of the pre-notched cantilevers. The function $f(a/w)$ is a shape factor and was determined by Matoy et al. [14] using FEM simulations. Cantilevers without pre-notch were used to calculate the fracture strength, σ_f , evaluated following classical bending beam theory:

$$\sigma = 6 \frac{F_{max} L}{B w^2} \quad (2)$$

For the structural and chemical characterization of the MGTs transmission electron microscopy (TEM) and atom probe tomography (APT) were utilized. Samples for TEM investigation were fabricated with an FEI Helios NanoLab 600 followed by a post thinning-process with illumination of 500 eV ion beam. Micrographs were recorded in an FEI Titan G2 80–200 CREWLEY at 200 kV with a high angle annular dark field (HAADF) detector with camera length of 110 mm, and a device controlling system of DigiScan and Digital Micrograph. Site-specific 3D-APT samples were prepared using an FEI Helios NanoLab 600i dual-beam FIB. The APT specimens were prepared following the standard lift-out process [15]. The APT measurements were performed on a commercial CAMECA local electrode atom probe LEAP 3000X HR, in voltage mode at a base temperature of 60 K, pulse repetition rate of 200 kHz and pulse fraction of 15%.

Topological analysis was performed by synchrotron X-ray diffraction at beamline P02.1 at the electron storage ring PETRA III (DESY, Hamburg, Germany). The X-ray diffraction was carried out in transmission along the CoTa-B compositional gradient of the MGTs deposited on polyimide foil [16]. A monochromatic photon beam with a spot size of $0.7 \text{ mm} \times 0.7 \text{ mm}$ and a wavelength of 0.02070 nm was used. The diffracted 2D patterns were recorded with a fast image plate detector Perkin Elmer 1621, positioned at a distance of 238 mm from the thin film. The sample to detector distance, orthogonality of the detector and beam centre was calibrated using a CeO_2 powder standard

(National Institute of Standards and Technology 674b). Individual diffraction patterns were acquired for 30 s. The diffraction patterns were integrated into q -space ($q = 4\pi \sin\theta/\lambda$) up to $18 \text{ \AA}^{-1}$ using the FIT2D software package [17]. The pair distribution functions (PDF) were obtained from the integrated diffraction intensity after correction for background contributions, sample absorption, inelastic scattering and normalization to the atomic X-ray form factor employing the PDFgetX2 software [18].

Finally, *ab initio* molecular dynamic simulations with the density functional theory [19] based openMX code [20, 21] were carried out. Electronic potentials with the generalised gradient approximation were employed [22]. Basis functions were linear combinations of localised pseudoatomic orbitals [23]. The following basis functions were applied: Co5.5-s2p1d1, Ta7.0-s2p1d1f1, B4.5-s2p2. The first symbol designates the chemical element followed by the cutoff radius. The last set of symbols defines the primitive orbitals. An N-point grid of $85 \times 85 \times 85$ and a cutoff energy of 150 Ry has been used. For volume relaxation at 0 K the Vienna Ab-initio Simulation Package was utilized [24, 25]. Thereby, the ultrasoft pseudopotentials were employed and the Brillouin zone was integrated on a $3 \times 3 \times 3$ Monkhorst-Pack k-point grid [26]. To model the short range ordered structure of the metallic glass, the structural model introduced by Hostert et al. [27] was applied with a supercell containing 115 atoms and 13 vacancies. In order to obtain an amorphous structure, the supercell was heated to 4000 K

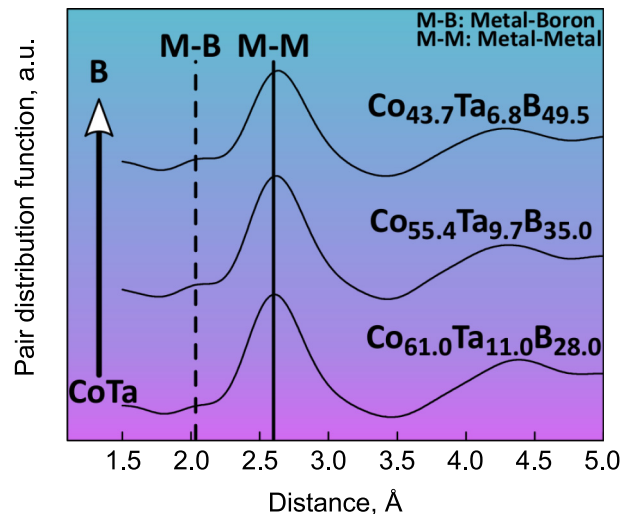


Fig. 2. Pair distribution functions with increasing B-content from bottom to top as obtained by high energy X-ray diffraction are presented in a range between 1.5 and 5.0 Å.

for 4000 fs and quenched to 0 K with infinite cooling rate until the volume change between two subsequent cycles was below 2%.

Fig. 1 shows the micro-mechanical behaviour of the MGTf as measured along the boron gradient. Micro-cantilever bending tests revealed an increase in fracture strength and fracture toughness as the boron content increases, Fig. 1a. For the material with the highest boron content probed, the fracture strength is in the range of 11 ± 0.4 GPa, i.e. twice as high as that observed for the ultra-high strength $\text{Co}_{43}\text{Fe}_{20}\text{Ta}_{5.5}\text{B}_{31.5}$ bulk metallic glass with a fracture strength of 5.2 GPa reported by Inoue et al. [3]. A fracture toughness of 6 MPa $\sqrt{\text{m}}$ is achieved for the material with highest boron composition and 2 MPa $\sqrt{\text{m}}$ for the lowest B content. Fig. 1b shows the hardness and reduced Young's modulus as a function of boron content as revealed by nanoindentation measurements. Both the reduced Young's modulus and hardness increase as boron content increases. For the highest investigated boron content, the reduced Young's modulus reaches a value of 344 ± 1.5 GPa, which is slightly higher than the record Young's modulus of 309 GPa reported by Ohtsuki et al. [28] for a $\text{W}_{46}\text{Re}_{37}\text{B}_{17}$ metallic glass. Representative fracture surfaces and load-deflection curves are given in the Supplementary Figs. 3 and 4, respectively.

To understand the superior stiffness, a short-range order analysis for $\text{Co}_{61.0}\text{Ta}_{11.0}\text{B}_{28.0}$, $\text{Co}_{55.4}\text{Ta}_{9.7}\text{B}_{35.0}$ and $\text{Co}_{43.7}\text{Ta}_{6.8}\text{B}_{49.5}$ was performed. Fig. 2 shows the real space pair distribution functions (PDF). For the $\text{Co}_{61.0}\text{Ta}_{11.0}\text{B}_{28.0}$ the maxima of the first order metal to boron bond

population at a distance of 2.02 Å is marked by a vertical dashed line. The first order metal to metal bond population is within the range of 2.2 to 3.4 Å, with its maxima marked by a second vertical line. Furthermore, the PDF analysis in Fig. 2 reveals a continuous shift of the metal-metal and metal boron bond population maxima with increasing boron content. The shift corresponds to a relative increase of 2.0% and 0.8% for the metal to boron and metal to metal bond distance, respectively. This increase in bond distance can be attributed to a similar weakening of the boron induced metallic bond as reported for Co–B based metallic glasses [16, 29]. The PDF also shows a boron-induced increase in the first order metal boron bond population corresponding to an increase in density of strong metal-to boron bonds [27, 30]. Based on the reports by Schnabel et al. [16, 31], an increase in boron content results in a concomitant increase of bond density as well as bond energy density [31]. Hence, the origin of the ultrahigh stiffness reported here in Fig. 1 is best understood in terms of the bond energy density [31].

To rationalize the observed micro-mechanical performance in terms of fracture strength and toughness, STEM and APT were performed specifically at the compositions $\text{Co}_{55.4}\text{Ta}_{9.7}\text{B}_{35.0}$ and $\text{Co}_{43.7}\text{Ta}_{6.8}\text{B}_{49.5}$ that showed a large difference in mechanical properties. HAADF-STEM analysis was initially conducted, where contrast arises due to changes in the average atomic weight. Fig. 3a and b show a lamellar structure inclined by approximately 20° with respect to the film growth axis and with compositional variations for both compositions, $\text{Co}_{55.4}\text{Ta}_{9.7}\text{B}_{35.0}$ and

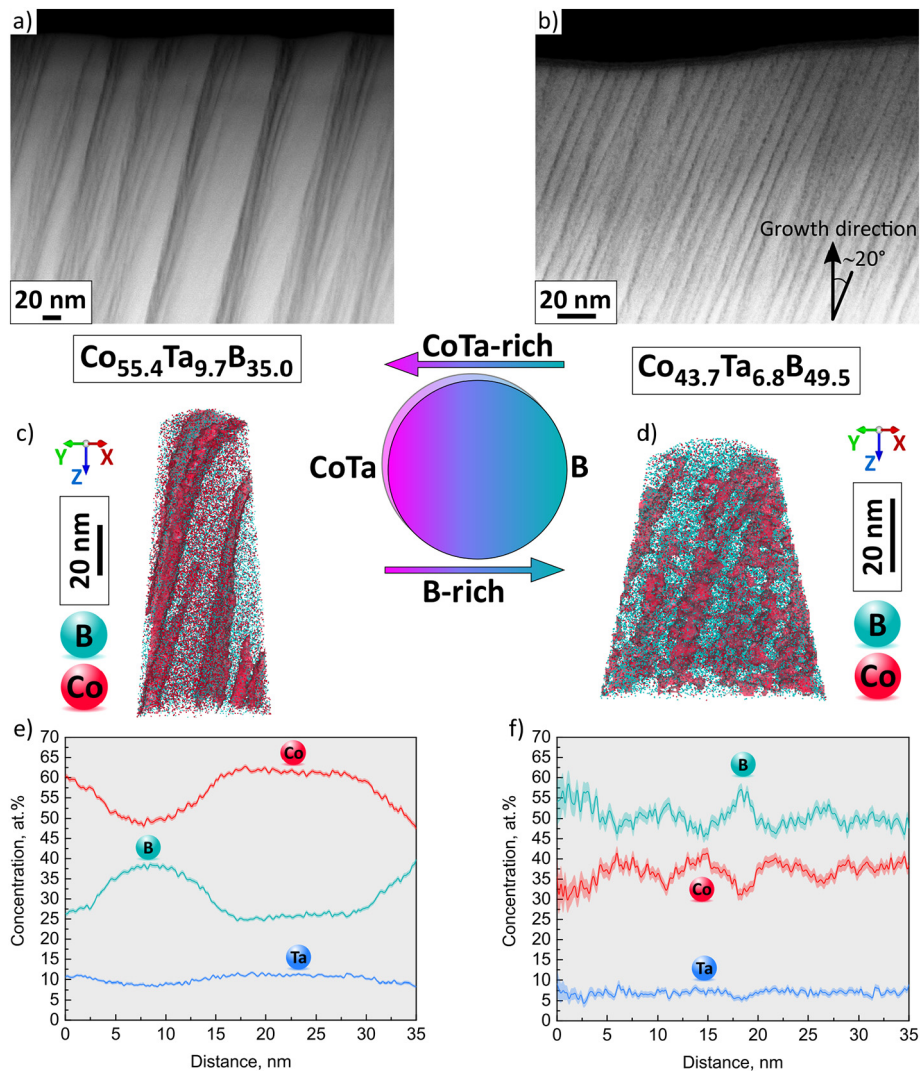


Fig. 3. a,b) HAADF-STEM micrographs revealing the lamellar structure for $\text{Co}_{55.4}\text{Ta}_{9.7}\text{B}_{35.0}$ and $\text{Co}_{43.7}\text{Ta}_{6.8}\text{B}_{49.5}$. c,d) Corresponding APT reconstructions from $\text{Co}_{55.4}\text{Ta}_{9.7}\text{B}_{35.0}$ and $\text{Co}_{43.7}\text{Ta}_{6.8}\text{B}_{49.5}$ compositions. e,f) Compositional profiles perpendicular to lamellar structures revealing the boron and cobalt variations.

$\text{Co}_{43.7}\text{Ta}_{6.8}\text{B}_{49.5}$. The lamellar structure becomes thinner and more refined for the MGTG with higher bulk boron content. These compositional variations are confirmed through the application of APT that shows a succession of boron enriched and boron depleted regions as shown in Fig. 3c–3f, for each individual bulk composition. In Fig. 3e and f, slight variations of tantalum across the lamellar structure was observed. STEM and APT analysis of regions with a boron content below 28 at.% shows a completely uniform microstructure with uniform distribution of cobalt, tantalum and boron.

These record fracture strength of the here reported nano-lamellar Co-based metallic glass thin film cannot be understood by any design notion entertained today. With a Poisson's ratio of 0.33 and 0.30 for $\text{Co}_{55}\text{Ta}_{10}\text{B}_{35}$ and $\text{Co}_{47}\text{Ta}_{6}\text{B}_{47}$, respectively, $\text{Co}_{55}\text{Ta}_{10}\text{B}_{35}$ is close to the tough-brittle transition and $\text{Co}_{47}\text{Ta}_{6}\text{B}_{47}$ clearly in the brittle regime, assuming the tough-brittle transition proposed by Lewandowski et al. [32]. Since the fingerprint for toughness can be found in the electronic structure [9], the electronic density of states (DOS) of $\text{Co}_{55}\text{Ta}_{10}\text{B}_{35}$ is shown in Fig. 4. The upper panel shows the total DOS, while the lower panels show the partial DOS of the constituents Co, Ta and B. The Fermi level is shifted to 0 eV. The d bands of Co and Ta are strongly overlapping between -6 and 0 eV. Comparing the d bands of Co and Ta with the shape of the B p band between -6.5 and -2 eV, an overlap between the p band of B and the d band of Co and Ta is visible. Therefore, a strong contribution of hybridized bonds to the overall bonding in $\text{Co}_{55}\text{Ta}_{10}\text{B}_{35}$ is expected. Thus, stiff behaviour of the material (with limited toughness) due to the prohibition of shear relaxation and of the formation of shear transformation zones is predicted. It may be speculated that the observed high fracture strength may be enabled by the nano-laminated (lamellar) architecture, whose origin is not understood yet and subject of ongoing work.

As the formation of lamellar structures within metallic glasses seems to result in excellent fracture strengths, it can be used as a design route for excellent mechanical performance. This design route is controlled by the process parameters of the PVD process. Phase separation occurring in the liquid during cooling of bulk metallic glasses is normally achieved with a large positive heat of mixing [33]. However, in the current example calculations of the enthalpies of mixing by the Calphad approach show that all enthalpies of mixing are negative and also the differences

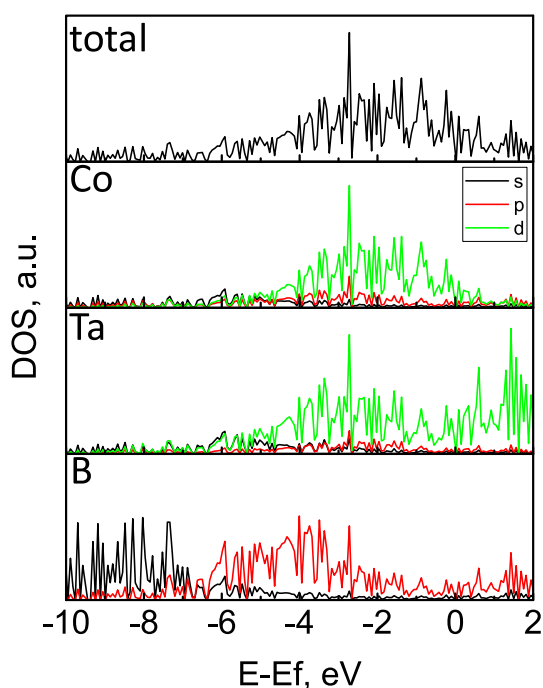


Fig. 4. Electronic density of states for CoTaB_{35} . Total DOS in the top panel, below the partial DOS for Co, Ta and B. The Fermi level is shifted to 0 eV.

of the interaction parameters are lower than reported for phase separation for metallic glasses in literature [34]. The cohesive energy for $\text{Co}_{55.4}\text{Ta}_{9.7}\text{B}_{35.0}$ was estimated by *ab initio* calculations. For a homogeneous supercell, a cohesive energy of -7.444 eV/atom was found. Based on the input from the APT measurements, a computational supercell was created containing a boron-rich $\text{Co}_{50}\text{Ta}_{10}\text{B}_{40}$ and a cobalt-rich $\text{Co}_{60}\text{Ta}_{10}\text{B}_{30}$ half, leading to a cohesive energy of -7.447 eV/atom. The energy difference of 3 meV/atom or 0.04% is not significant, indicating that both phases are thermodynamically equally (meta-) stable. As the formation of the lamellar structure cannot be interpreted by thermodynamics, it is believed that its formation is kinetically driven. This is in agreement with observations made on completely DC sputtered samples of same composition where a homogeneous structure was observed, compared to the lamellar structure found in the MGTG, where boron was RF sputtered.

In summary, our findings provide a new design route for a cobalt tantalum-based metallic glass thin films with enhanced mechanical performance as a function of boron content. A compositional lamellar structure revealed by TEM shows that the lamella thickness decreases as boron content increases. A substantial compositional difference was observed within the lamellar structure, where boron- and cobalt-rich structures were revealed by atom probe tomography. As the thickness of the lamellar structure decreases, fracture toughness and fracture strength are enhanced, suggesting the origin of the enhanced mechanical properties in the nanolaminated structure. The origin of the lamella formation is subject of ongoing research.

Supplementary data to this article can be found online at <https://doi.org/10.1016/j.scriptamat.2018.06.015>.

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